

STD LSNitride2 5/9/2018	OLD RECIPE
Date	5/9/18
Standard LS Nitride2 Coat	
Coat time, min	10
Standard LS Nitride2 Deposition	
Deposition time, min	30
LF power setup, W	80
RF power setup, W	30
LF time, sec	1.25
HF time, sec	6
Pressure, mTorr	800
Gass flow, sccm	
2%SiH	520
NH3	18
N2	980
T, C	~300
Thickness, nm	231.29
Dep.rate, nm/min	7.71
Index at 632.8nm	1.956
Index at 1550nm	1.920
Stress, MPa	-4.86
BHF, nm/min	34.42
Std. clean, min	40

